利用超深 X 光光刻技術製造兆赫頻段二維光子晶體之研究

The Study on Fabrication of Two-Dimensional Photonic Crystal in THz Range Using Ultra Deep X-ray Lithography Technique

研究生:李漢傑 Student:Han-Chieh Li

指導教授:周長彬 Advisor:Chang-Pin Chou

許博淵 Bor-Yuan Shew

國立交通大學



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